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CHANG et al.(10) **Pub. No.: US 2011/0063535 A1**(43) **Pub. Date: Mar. 17, 2011**(54) **PIXEL STRUCTURE OF LIQUID CRYSTAL
DISPLAY PANEL****Publication Classification**

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(57) **ABSTRACT**

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Taipei County (TW)(21) **Appl. No.:** **12/730,898**(22) **Filed:** **Mar. 24, 2010**(30) **Foreign Application Priority Data**

Sep. 11, 2009 (TW) 098130656

A pixel structure of a liquid crystal display panel includes a substrate, a first metallic layer, a light shielding element, a second metallic layer and a pixel electrode. The first metallic layer and the light shielding element are disposed above the substrate. The second metallic layer is disposed above the light shielding element, and includes first and second data lines. The first data line is disposed along the light shielding element, and is partially overlapped with the light shielding element. The second data line is parallel to the first data line. A first portion of the pixel electrode is overlapped with the first data line, and is not overlapped with the light shielding element. A second portion of the pixel electrode is overlapped with the light shielding element, and is not overlapped with the first data line.

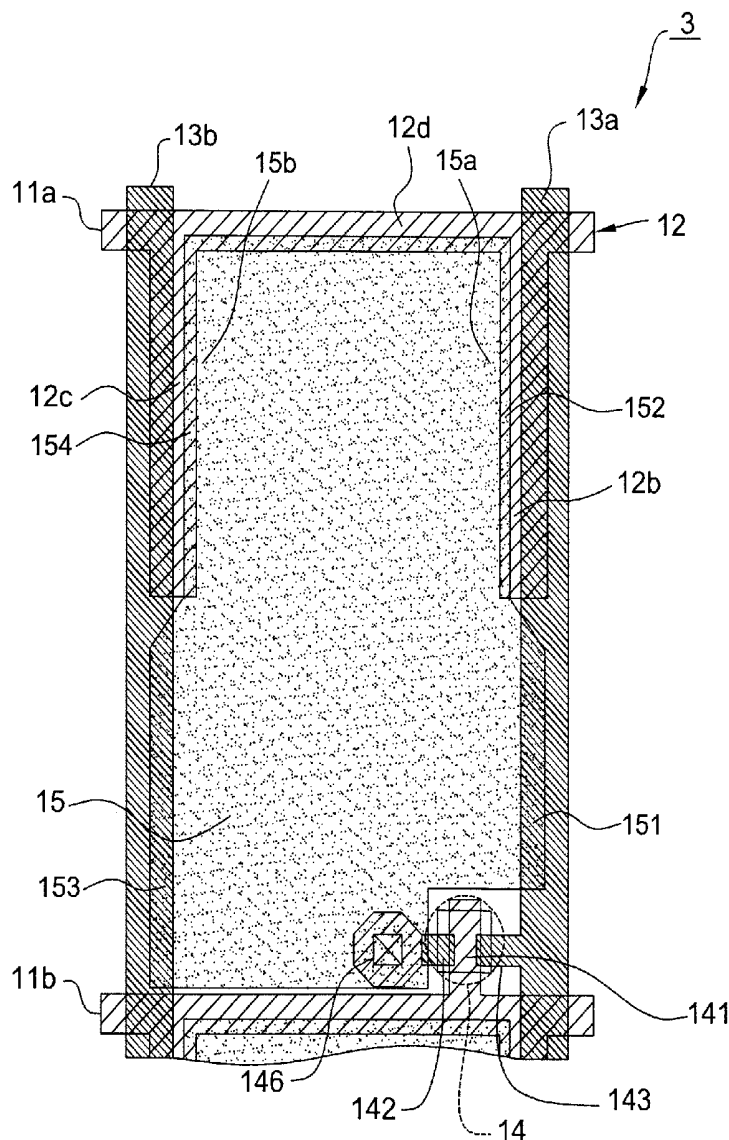


FIG.2(PRIOR ART)

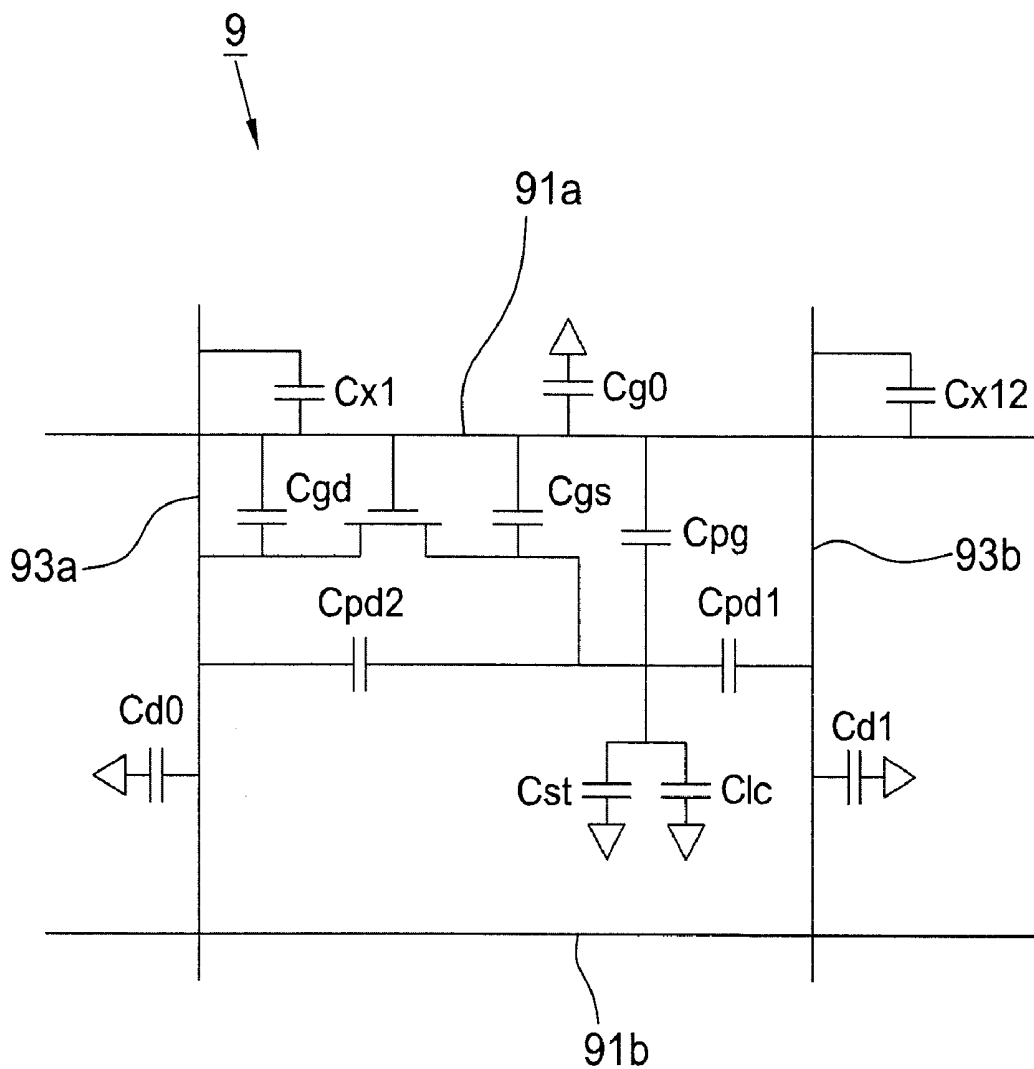


FIG.3(PRIOR ART)

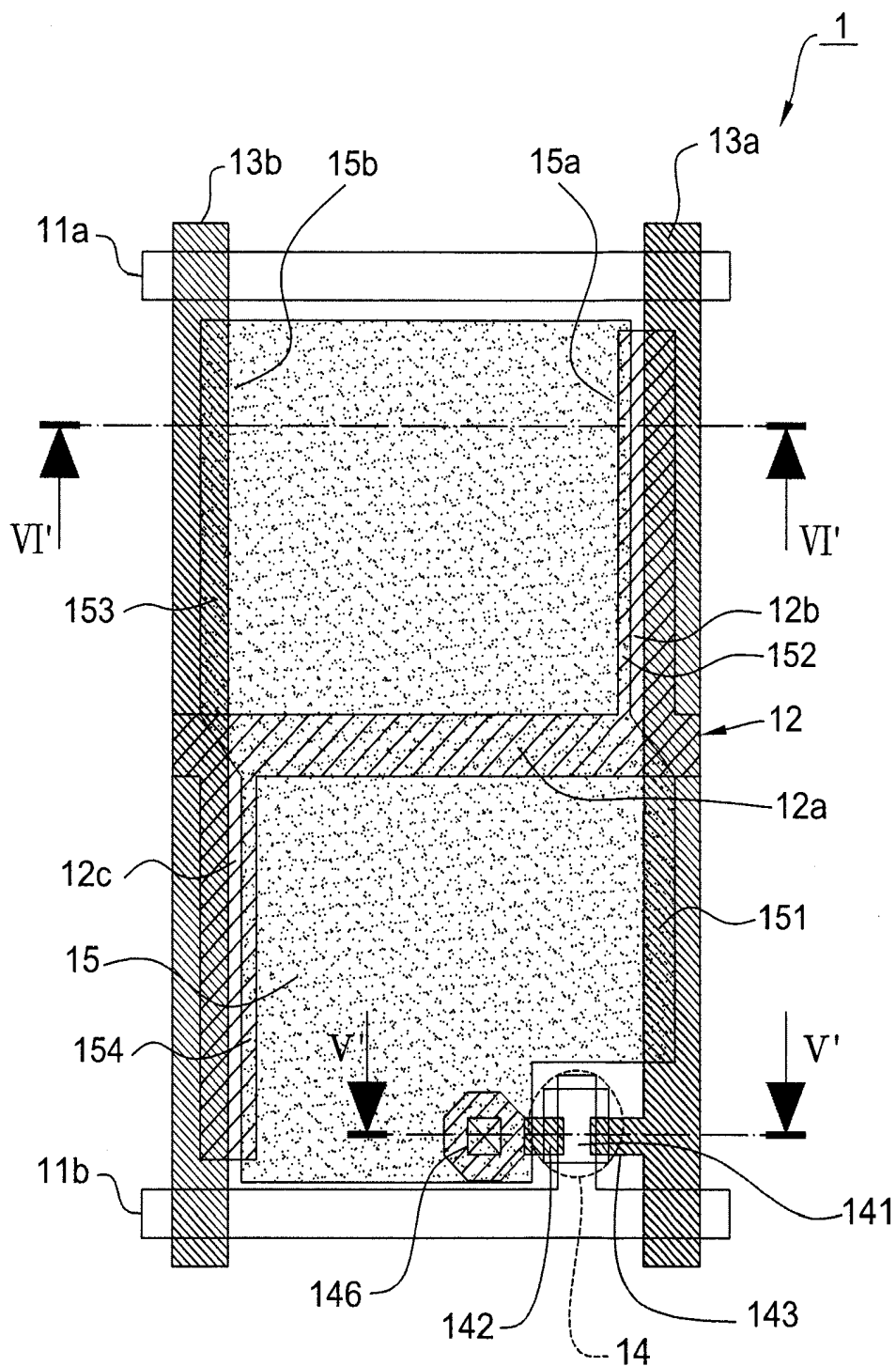


FIG.4a

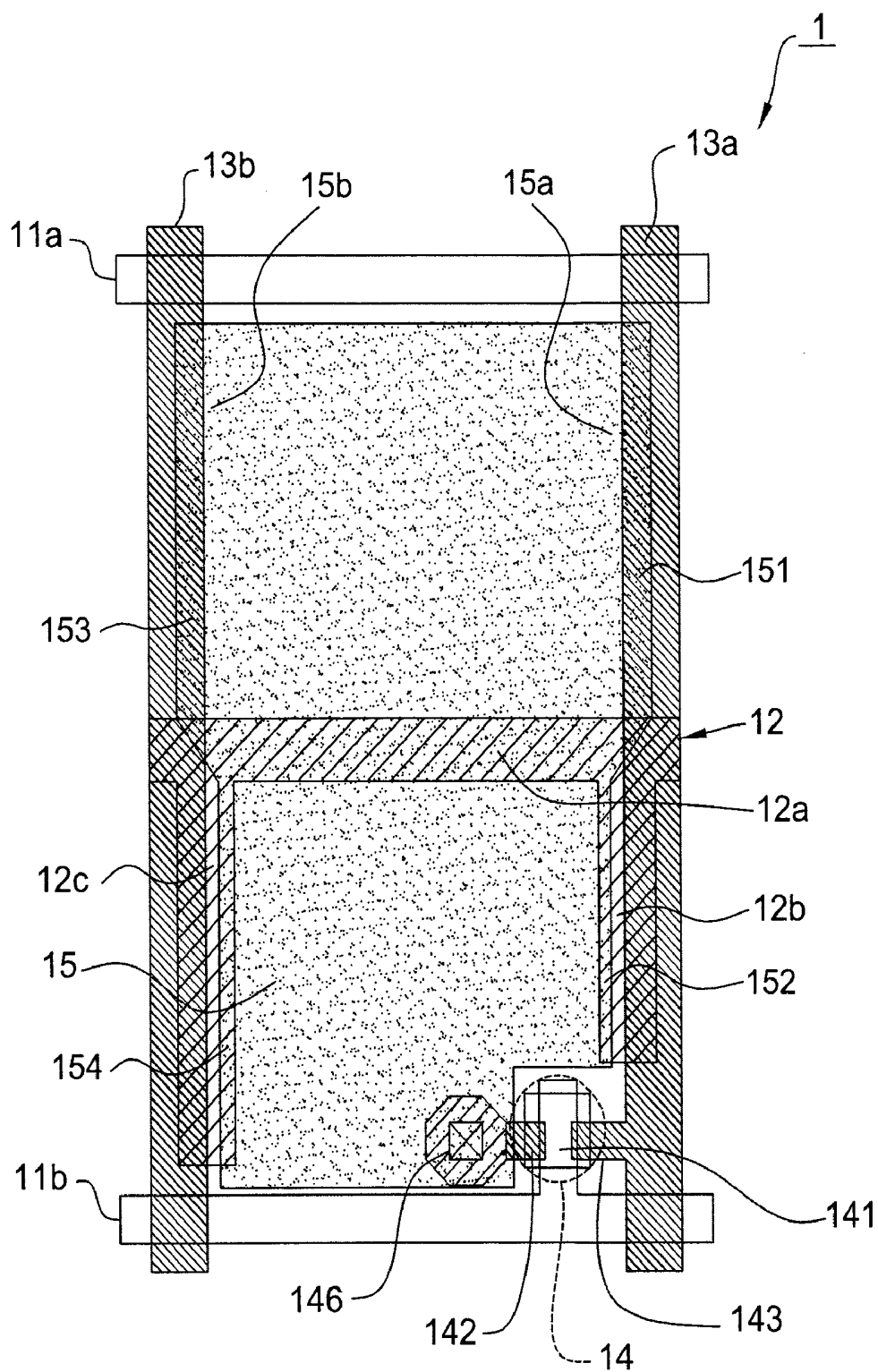


FIG.4b

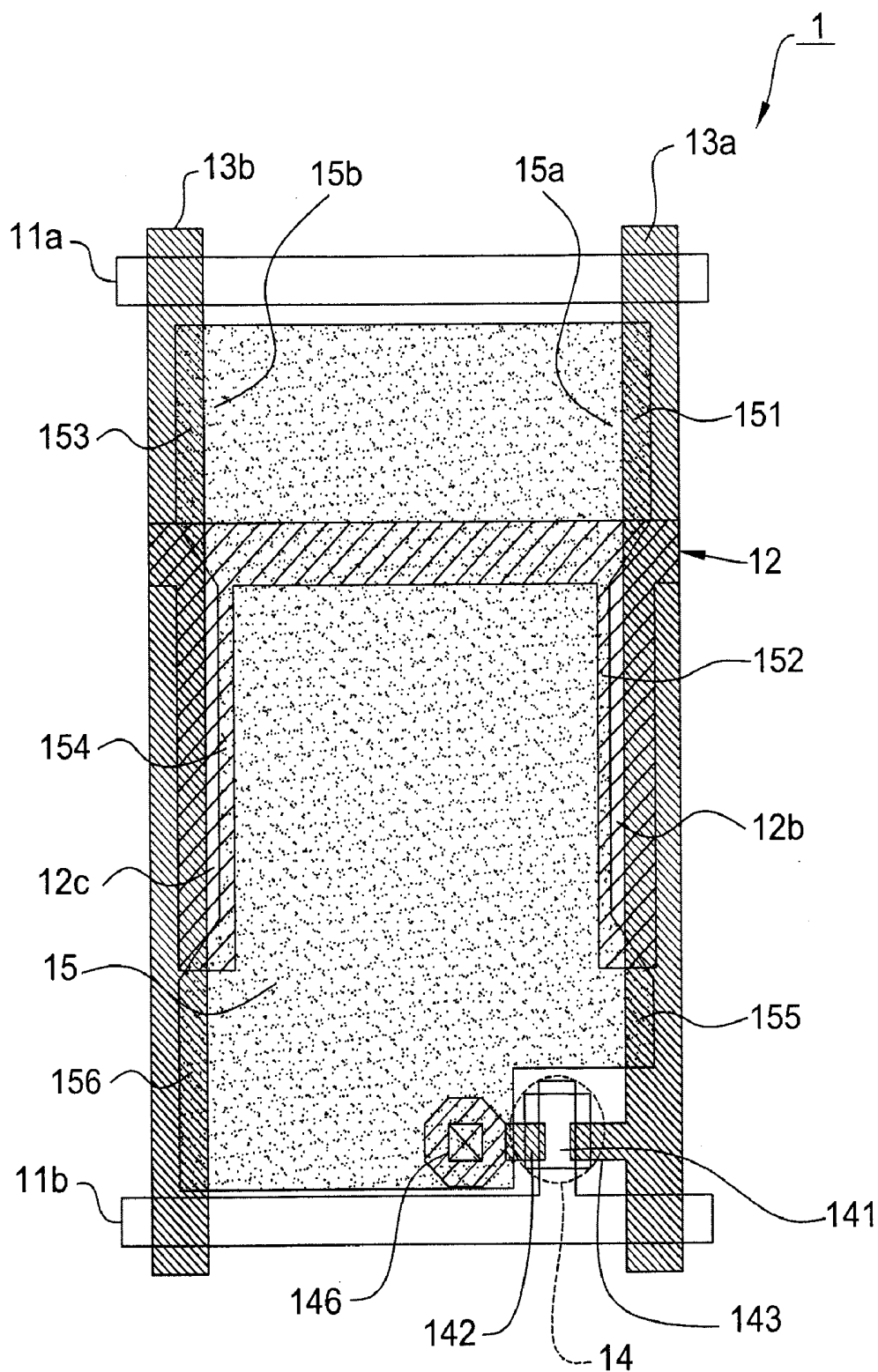


FIG.4c

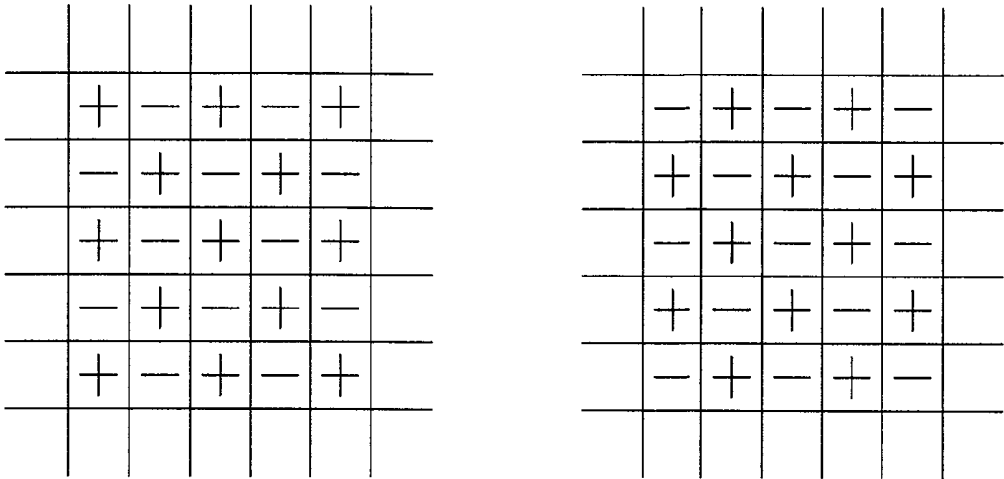


FIG.5a

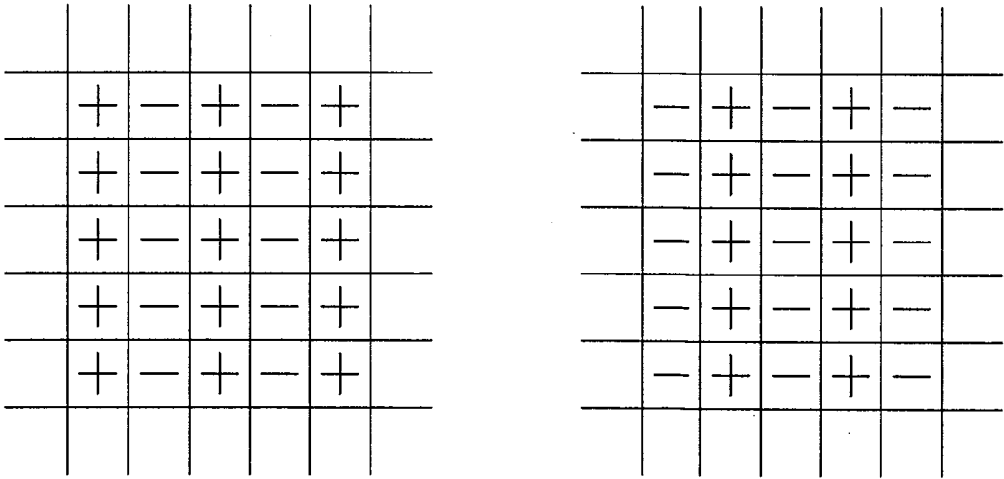


FIG.5b

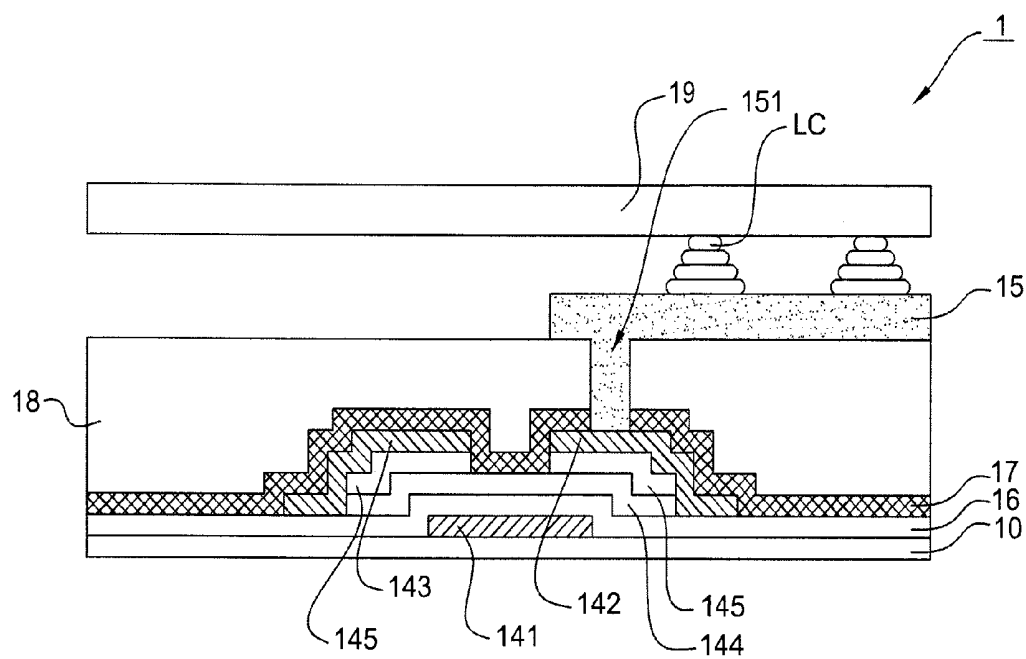


FIG. 6a

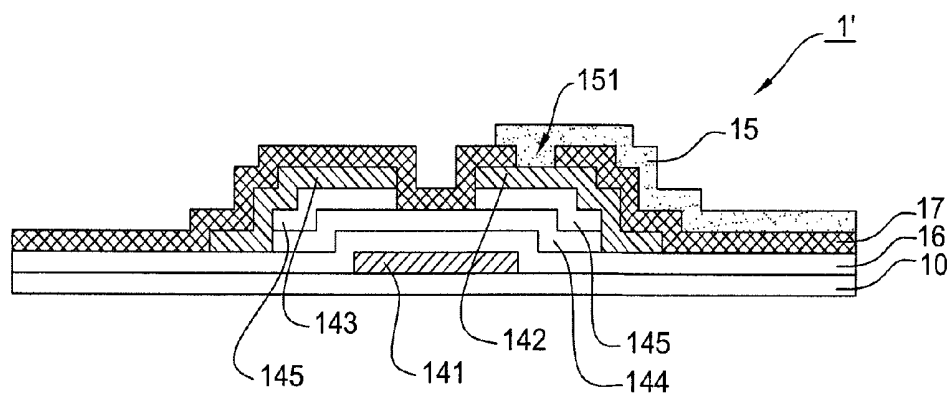


FIG. 6b

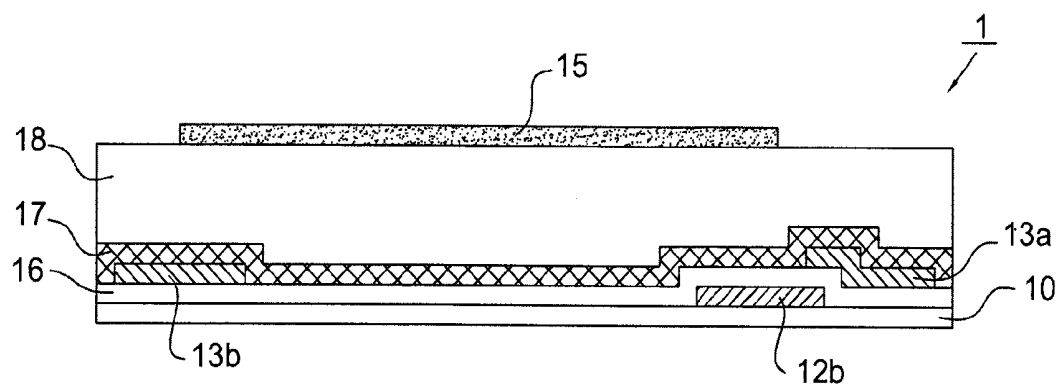


FIG. 7a

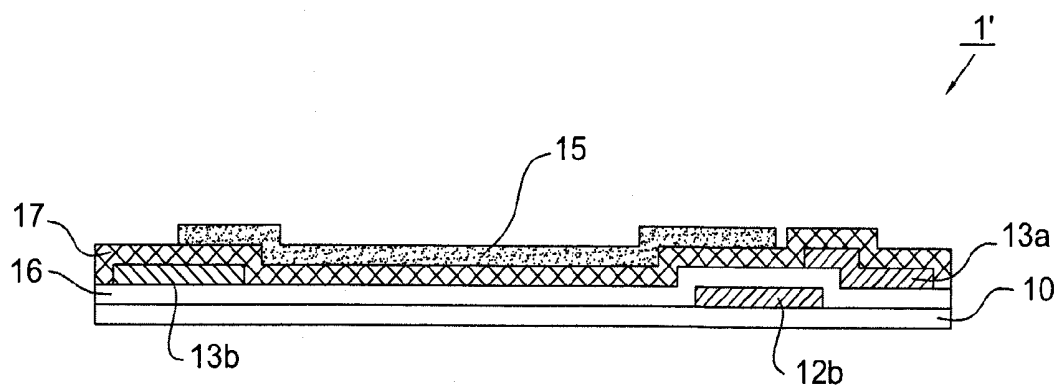


FIG. 7b

FIG.8

FIG.9

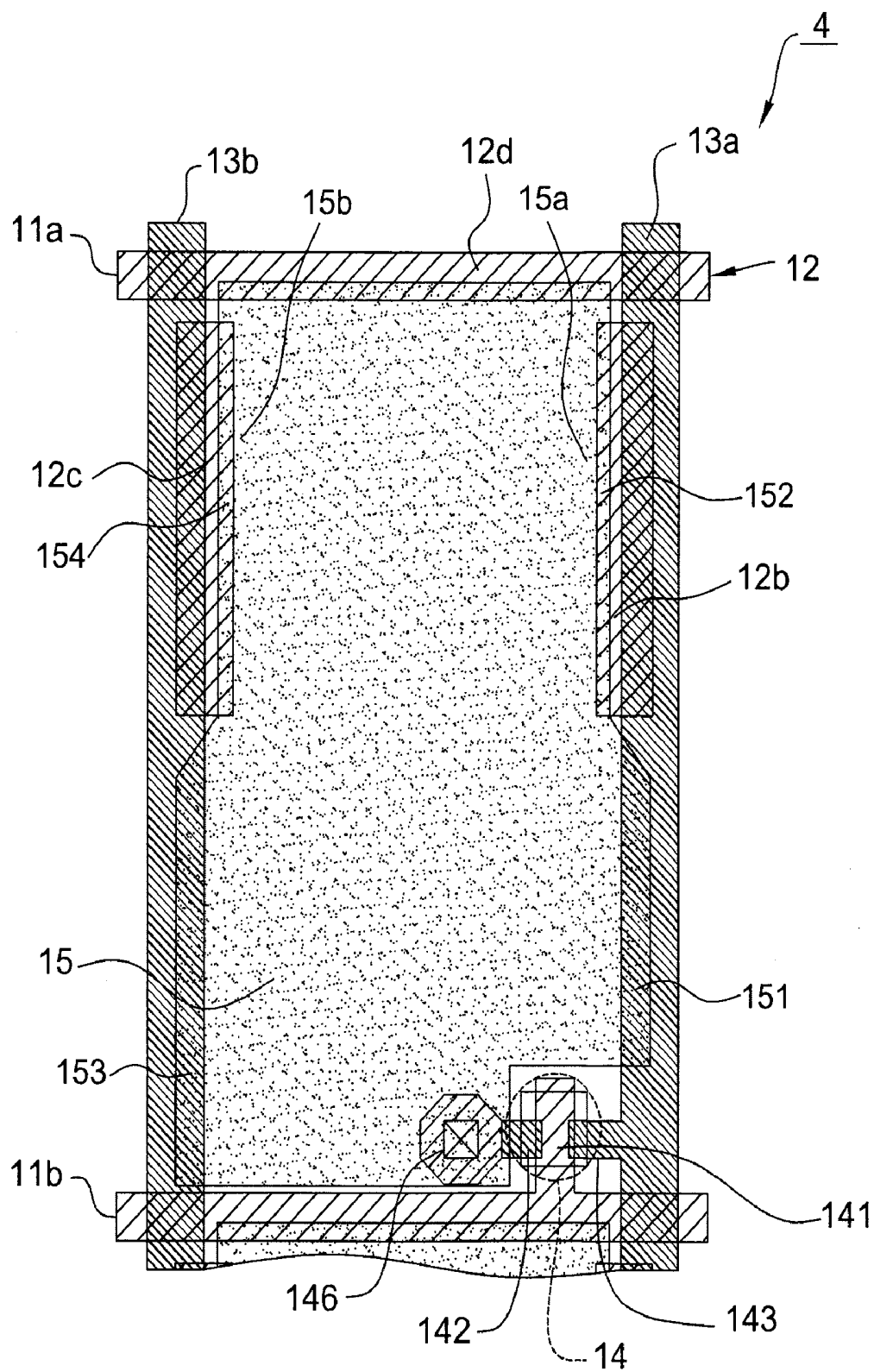


FIG.10

PIXEL STRUCTURE OF LIQUID CRYSTAL DISPLAY PANEL

CROSS REFERENCE TO RELATED APPLICATION

[0001] This application claims the priority benefit of Taiwan Patent Application Serial Number 098130656, filed on Sep. 11, 2009, the full disclosure of which is incorporated herein by reference.

TECHNICAL FIELD

[0002] The invention is related to a liquid crystal display panel, and more particularly to a pixel structure of a liquid crystal display panel, wherein the coupling ratio of two data lines in a single pixel region can be reduced.

BACKGROUND

[0003] Accompanying with the improvement of electronic technology, especially the popularity of portable electronic products in daily life, there is an increased demand for light, compact and low power consumption display devices. Since a liquid crystal display has the merits of low power consumption, compact and light, it is suitable for this kind of electronic products and even gradually replaces conventional cathode ray tube (CRT) devices.

[0004] Since the pixel aperture ratio is an important factor that has an effect on the characteristics of liquid crystal displays, several kinds of pixel structures have been proposed so far to increase the pixel aperture ratio. Referring to FIGS. 1 and 2, FIG. 1 shows a plan view of a conventional pixel structure with high aperture ratio while FIG. 2 shows a cross-sectional view taken along the line II'-II' of FIG. 1. The pixel structure 9 includes two gate lines 91a, 91b and one conductive line 92 formed parallel in a row, and includes two data lines 93a, 93b perpendicular to the gate lines 91a, 91b and the conductive line 92, wherein the conductive line 92 has a first part 92a serving as a common line and has a second part 92b serving as a storage capacitor, and the width of the second part 92b is larger than that of the first part 92a. The two gate lines 91a, 91b and the two data lines 93a, 93b define a pixel region.

[0005] A thin film transistor 95 is disposed adjacent to an intersection of the gate line 91a and the data line 93a and includes a gate electrode extended from the gate line 91a, a semiconductor layer 951 formed above the gate electrode. An insulating layer 98 is sandwiched between the semiconductor layer 951 and the gate electrode, as shown in FIG. 2. A source electrode 953 and a drain electrode 952 are overlapped with portions of two sides of the semiconductor layer 951 respectively. An organic insulating layer 97 is formed over the pixel region and a pixel electrode 96 is further stacked thereon. A contact hole 99 is provided through the organic insulating layer 97 so as to electrically connect the pixel electrode 96 to the source electrode 953, wherein the pixel electrode 96 is overlapped with the two gate lines 91a, 91b and the two data lines 93a, 93b respectively, thereby increasing the aperture ratio of the pixel structure 9.

[0006] However, according to the above pixel structure 9, an organic insulating layer 97 is disposed to decrease the parasitic capacitance Cpd existed between the pixel electrode 96 and the data lines 93a, 93b, thereby reducing crosstalk. Referring to FIG. 3, it shows the connection between capacitors in a pixel region. With reference to this drawing, the coupling ratio of the data lines 93a, 93b in a single pixel

region can be obtained as $(Cpd1+Cpd2)/[(Cpd1+Cpd2)+Cst+Clc+(Cgs+Cpg)]$, wherein the pixel region is defined by two adjacent gate lines 91a, 91b and two adjacent data lines 93a, 93b, (Cpd1+Cpd2) is the parasitic capacitance induced by the overlapping of a pixel electrode with two data lines of this pixel region, Cst is the storage capacitance of the pixel region, Clc is the capacitance of liquid crystal unit, Cgs is the parasitic capacitance between a gate electrode and a source electrode of the thin film transistor, Cpg is the capacitance between a pixel electrode and a gate electrode of the thin film transistor. If the coupling ratio in a single pixel region becomes smaller, the crosstalk becomes smaller. Also, according to the above equation, the coupling ratio can be reduced by decreasing the value of (Cpd1+Cpd2) or by increasing the value of Cst.

[0007] Referring to FIGS. 1 and 2 again, although the parasitic capacitance Cpd between the pixel electrode 96 and the data lines 93a, 93b can be reduced by disposing an organic insulating layer 97 in the pixel structure 9, the storage capacitance Cst between the pixel electrode 96 and the second part 92b of the conductive line 92 will also be reduced simultaneously. Therefore, the coupling ratio in a single pixel region is not able to be efficiently reduced.

[0008] Accordingly, there exists a need for a pixel structure of a liquid crystal display panel capable of solving the above-mentioned problems.

SUMMARY

[0009] The present invention provides a pixel structure of a liquid crystal display panel includes a substrate, a first metallic layer, a first light shielding element, a second metallic layer and a pixel electrode. The first metallic layer is disposed above the substrate and includes first and second gate lines laterally parallel to each other. The first light shielding element is disposed above the substrate. The second metallic layer is disposed above the first light shielding element, and includes first and second data lines. The first data line is disposed along the first light shielding element, and is partially overlapped with the first light shielding element. The second data line is parallel to the first data line, wherein the first gate line, the second gate line, the first data line and the second data line together define a pixel region. The pixel electrode has a first side, which includes a first portion and a second portion. The first portion is overlapped with the first data line, and is not overlapped with the first light shielding element. Also, the second portion is overlapped with the first light shielding element, and is not overlapped with the first data line. The pixel structure further includes a second light shielding element parallel to the first light shielding element. The second data line is disposed along the second light shielding element, and is partially overlapped with the second light shielding element. The pixel electrode has a second side, which includes a third portion and a fourth portion, wherein the third portion is overlapped with the second data line, and the third portion is not overlapped with the second light shielding element.

[0010] The liquid crystal display panel is operated in a dot inversion mode or a column inversion mode. By utilizing the two adjacent pixel regions having opposite polarity, the coupling ratio of two data lines in a single pixel region can be reduced.

BRIEF DESCRIPTION OF THE DRAWINGS

[0011] Embodiments of the present invention are illustrated by way of example, and not by limitation, in the figures

of the accompanying drawings, wherein elements having the same reference numeral designations represent like elements throughout and wherein:

[0012] FIG. 1 is a plan view of a pixel structure of a liquid crystal display panel in the prior art;

[0013] FIG. 2 is a cross-sectional view taken along the line II'-II' of the pixel structure shown in FIG. 1;

[0014] FIG. 3 is a schematic view showing the connection between capacitors in a pixel structure in the prior art.

[0015] FIG. 4a is a plan view of the pixel structure of a liquid crystal display panel according to a first embodiment of the present invention;

[0016] FIG. 4b is a plan view of the pixel structure of a liquid crystal display panel according to another embodiment of the present invention;

[0017] FIG. 4c is a plan view of the pixel structure of a liquid crystal display panel according to a further embodiment of the present invention;

[0018] FIGS. 5a and 5b respectively show that the liquid crystal display panel is operated in a dot inversion mode and a column inversion mode, and two adjacent pixel regions having opposite polarity;

[0019] FIG. 6a is a cross-sectional view taken along the line V'-V' of the pixel structure shown in FIG. 4a, wherein the pixel structure includes an organic layer;

[0020] FIG. 6b is a cross-sectional view taken along the line V'-V' of the pixel structure shown in FIG. 4a, wherein the pixel structure does not include an organic layer;

[0021] FIG. 7a is a cross-sectional view taken along the line VI'-VI' of the pixel structure shown in FIG. 4a, wherein the pixel structure includes an organic layer;

[0022] FIG. 7b is a cross-sectional view taken along the line VI'-VI' of the pixel structure shown in FIG. 4a, wherein the pixel structure does not include an organic layer;

[0023] FIG. 8 is a plan view of the pixel structure of a liquid crystal display panel according to a second embodiment of the present invention;

[0024] FIG. 9 is a plan view of the pixel structure of a liquid crystal display panel according to a third embodiment of the present invention; and

[0025] FIG. 10 is a plan view of the pixel structure of a liquid crystal display panel according to a fourth embodiment of the present invention;

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENT

[0026] The foregoing, as well as additional objects, features and advantages of the invention will be more apparent from the following detailed description, which proceeds with reference to the accompanying drawings. In addition, it should be noticed that, wherever possible, the same reference numbers will be used throughout the drawings to refer to the same or like parts.

[0027] Referring to FIG. 4a, it shows a top plan view of the pixel structure 1 of a liquid crystal display panel according to the first embodiment of the present invention. The pixel structure 1 includes a first gate line 11a, a second gate line 11b, a conductive line 12, a first data line 13a and a second data line 13b. The second gate line 11b and the first gate line 11a are laterally parallel to each other. The conductive line 12 includes a common line 12a and first and second light shielding elements 12b, 12c. The first and second light shielding elements 12b, 12c are longitudinally parallel to each other, and the common line 12a is electrically connected to the first

and second light shielding elements 12b, 12c. The first data line 13a is perpendicular to the first gate line 11a, the second gate line 11b and the common line 12a. Also, the first data line 13a is disposed along the first light shielding element 12b, and is partially overlapped with the first light shielding element 12b. The second data line 13b is parallel to the first data line 13a. Also, the second data line 13b is disposed along the second light shielding element 12c, and is partially overlapped with the second light shielding element 12c. The first gate line 11a, the second gate line 11b, the first data line 13a and the second data line 13b together define a pixel region. It is apparent to one of ordinary skill in the art that the pixel structure 1 can also include a plurality of pixel regions.

[0028] The first gate line 11a and the second gate line 11b are served as scan lines. The first and second gate lines 11a, 11b and the conductive line 12 are formed by the same photolithography & etching processes, and hence the first and second gate lines 11a, 11b and the conductive line 12 are referred to first metal layer (M1) herein. After the first metal layer is formed, the first and second data lines 13a, 13b are formed by the same photolithography & etching processes, and hence the first and second data lines 13a, 13b are referred to second metal layer (M2) herein. In this embodiment, the conductive line 12 is made of conductive material, and the first and second light shielding elements 12b, 12c are adapted to block light leakage at the edge of the pixel structure 1.

[0029] The area of the black matrix (not shown) between two adjacent pixels can be reduced by disposing the first and second light shielding elements 12b, 12c of the conductive line 12 to block light leakage at the edge of a pixel region so as to increase the transmission rate of a single pixel structure, thereby increasing the aperture ratio of the pixel structure 1.

[0030] A thin film transistor 14 is disposed adjacent to an intersection of the second gate line 11b and the first data line 13a. The thin film transistor 14 includes a gate electrode 141, a source electrode 142 and a drain electrode 143, wherein the gate electrode 141 is extended from the second gate line 11b. A pixel electrode 15 is deposited over the pixel region. The pixel electrode 15 has a first side 15a, which includes a first portion 151 and a second portion 152. The first portion 151 is overlapped with the first data line 13a, and is not overlapped with the first light shielding element 12b. The second portion 152 is overlapped with the first light shielding element 12b, and is not overlapped with the first data line 13a. Also, the pixel electrode 15 has a second side 15b, which includes a third portion 153 and a fourth portion 154. The third portion 153 is overlapped with the second data line 13b, and is not overlapped with the second light shielding element 12c. The fourth portion 154 is overlapped with the second light shielding element 12c, and is not overlapped with the second data line 13b. In this embodiment, the first portion 151 and the third portion 153 are symmetrical at the right and lower position and the left and upper position, and the second portion 152 and the fourth portion 154 are symmetrical at the right and upper position and the left and lower position, shown in FIG. 4a. In another embodiment, the first portion 151 and the third portion 153 are symmetrical at the right position and the left position, and the second portion 152 and the fourth portion 154 are symmetrical at the right position and the left position, shown in FIG. 4b. According to the pixel structure 1 of this embodiment and another embodiment, the parasitic capacitance C_{pd} existed between the pixel electrode 15 and the data lines 13a, 13b can be half decreased, thereby reducing the coupling ratio of the data lines 13a, 13b in a

single pixel region, and further reducing crosstalk. Furthermore, an overlapping portion of the pixel electrode **15** and the conductive line **12** can be served as storage capacitor.

[0031] In a further embodiment, the first side **15a** further includes a fifth portion **155**, wherein the fifth portion **155** is overlapped with the first data line **13a**, and is not overlapped with the first light shielding element **12b**. Also, the second side **15b** further includes a sixth portion **156**, wherein the sixth portion **156** is overlapped with the second data line **13b**, and is not overlapped with the second light shielding element **12c**, shown in FIG. **4c**. According to the pixel structure **1** of a further embodiment, the parasitic capacitance Cpd existed between the pixel electrode **15** and the data lines **13a**, **13b** can be half decreased, thereby reducing the coupling ratio of the data lines **13a**, **13b** in a single pixel region, and further reducing crosstalk.

[0032] In addition, the present invention provides a method for driving a liquid crystal display panel. Referring to FIG. **5a**, the liquid crystal display panel is operated in a dot inversion mode, or referring to FIG. **5b**, the liquid crystal display panel is operated in a column inversion mode. The pixel structure **1** includes a plurality of pixel regions, which are adjacent to one another. By utilizing the two adjacent pixel regions having opposite polarity, it can get a formula: " $|Cpd1 + Cpd2| < |Cpd1| + |Cpd2|$," thereby reducing the coupling ratio of two data lines in a single pixel region, wherein Cpd1 and Cpd2 are parasitic capacitance existed between the pixel electrode and two adjacent data lines respectively, $|Cpd1 + Cpd2|$ is the absolute value of the sum of Cpd1 and Cpd2, and $|Cpd1| + |Cpd2|$ is the sum of the absolute value of Cpd1 and the absolute value of Cpd2. Preferably, the overlapping area between the pixel electrode **15** and the first data line **13a** is substantially equal to the overlapping area between the pixel electrode **15** and the second data line **13b**, whereby the value of $|Cpd1|$ is substantially equal to the value of $|Cpd2|$. When the pixel region of the liquid crystal display panel is operated, the pixel region is induced by coupled voltages of opposite polarity from the first and second data lines **13a**, **13b**, Cpd1 and Cpd2 can be offset (i.e. compensated) to each other, thereby further reducing crosstalk. According to the pixel structure **1** of this embodiment and another embodiment, for example, the overlapping area between the first portion **151** of the pixel electrode **15** and the first data line **13a** is substantially equal to the overlapping area between the third portion **153** of the pixel electrode **15** and the second data line **13b**. According to the pixel structure **1** of a further embodiment, the sum of the overlapping area between the first portion **151** of the pixel electrode **15** and the first data line **13a** and the overlapping area between the fifth portion **155** of the pixel electrode **15** and the first data line **13a** is substantially equal to the sum of the overlapping area between the third portion **153** of the pixel electrode **15** and the second data line **13b** and the overlapping area between the sixth portion **156** of the pixel electrode **15** and the second data line **13b**.

[0033] Referring to FIGS. **6a**, **6b**, **7a** and **7b**, FIGS. **6a** and **6b** show cross-sectional views taken along the line V'-V' of the pixel structure **1** shown in FIG. **4a**, and FIGS. **7a** and **7b** show cross-sectional views taken along the line VI'-VI' of the pixel structure **1** shown in FIG. **4a**. FIGS. **6a** and **7a** show an example of the pixel structure **1** according to the first embodiment of the present invention having an organic layer and it is a structure of storage capacitor on common (Cst on common). The pixel structure **1** includes a lower substrate **10**, e.g. a glass substrate. The gate electrode **141**, the common line **12a**, and

the first and second light shielding elements **12b**, **12c** of the conductive line **12** (first metal layer) are directly formed on the substrate **10**. A first insulating layer, e.g. gate insulating layer **16** is deposited on the lower substrate **10** to cover the gate electrode **141**, the common line **12a**, and the first and second light shielding elements **12b**, **12c** of the conductive line **12**. An amorphous silicon layer **144** and a doping layer **145** are successively deposited on the gate insulating layer **16** over the gate electrode **141**. A source electrode **142** and a drain electrode **143** are formed above both sides of the gate electrode **141** respectively, shown as FIG. **6a**. The first data line **13a** and the second data line **13b** are formed on the gate insulating layer **16**. The source electrode **142**, the drain electrode **143**, the first data line **13a** and the second data line **13b** are patterned by the same photolithography & etching process (second metal layer). A second insulating layer, e.g. inorganic passivation layer **17** is formed on the gate insulating layer **16** so as to cover the source electrode **142**, the drain electrode **143**, the first data line **13a** and the second data line **13b**. An organic layer **18** is directly formed on the passivation layer **17**, wherein the organic layer **18** has a thickness such as 3 micrometers. A pixel electrode **15** is directly deposited on the organic layer **18**. A contact hole **146** is formed through the organic layer **18** and the passivation layer **17** such that the pixel electrode **15** can be electrically connected to the source electrode **142** through the contact hole **146**. In addition, the pixel structure **1** further includes an upper substrate **19** and a liquid crystal layer LC, wherein the upper substrate **19** is opposite to the lower substrate **10**, and the liquid crystal layer LC is sandwiched between the lower substrate **10** and the upper substrate **19**.

[0034] In this embodiment, the material of the passivation layer **17** may be, but not limited to, silicon nitride, silicon oxy-nitride or silicon oxide. The material of the pixel electrode **15** is transparent conductive material, such as, but not limited to, indium tin oxide (ITO), indium zinc oxide (IZO) or aluminum doped zinc oxide (AZO).

[0035] FIGS. **6b** and **7b** show an example of the pixel structure **1** according to the first embodiment of the present invention without an organic layer. The differences between the pixel structure **1'** shown in FIGS. **6b** and **7b** and the pixel structure **1** shown in FIGS. **6a** and **7a** are that, the pixel electrode **15** is directly deposited on the passivation layer **17**, and a contact hole **146** is formed through the passivation layer **17** for electrically connecting the pixel electrode **15** to the source electrode **142** of the thin film transistor **14**, wherein the thickness of the passivation layer **17** can be increased to between 4500 Å and 9000 Å. In addition, the disposition of other elements is similar to that shown in FIGS. **6a** and **7a** and details will not be illustrated herein. Since it is necessary that the organic layer **18** is formed in this example, it is able to simplify the structure and reduce the manufacturing cost. Furthermore, the pixel structure **1'** shown in FIGS. **6b** and **7b** can also achieve the function of the pixel structure **1** shown in FIGS. **6a** and **7a**, wherein the function is to reduce the coupling ratio of the data lines in a single pixel region.

[0036] Referring to FIG. **8**, it shows a top plan view of the pixel structure **2** according to the second embodiment of the present invention. The difference between the pixel structure **2** in the second embodiment and the pixel structure **1** in the first embodiment (shown in FIG. **4a**) is that the first light shielding elements **12b** is separated from the common line **12a**, and the second light shielding elements **12c** is separated from the common line **12a**. Thus, the first and second light

shielding elements **12b**, **12c** can be made of conductive or insulating material. In addition, the deposition of other elements in the second embodiment is similar to that in the first embodiment shown in FIG. **4a** and details will not be illustrated herein. Similarly, the second embodiment of the present invention also includes the example having an organic layer (as those shown in FIGS. **6a** and **7a**) and the example without an organic layer (as those shown in FIGS. **6b** and **7b**).

[0037] Referring to FIG. **9**, it shows a top plan view of the pixel structure **3** of a liquid crystal display according to the third embodiment of the present invention. The pixel structure **3** includes a first gate line **11a**, a second gate line **11b**, a first data line **13a**, a second data line **13b** and a conductive line **12**. The conductive line **12** includes a line portion **12d**, and first and second light shielding elements **12b**, **12c**. The line portion **12d** is electrically connected to the first and second light shielding elements **12b**, **12c**, and is a part of the first gate line **11a**. The first and second light shielding elements **12b**, **12c** are longitudinally disposed. The first data line **13a** is perpendicular to the first gate line **11a** and the second gate line **11b**. Also, the first data line **13a** is disposed along the first light shielding element **12b**, and is partially overlapped with the first light shielding element **12b**. The second data line **13b** is parallel to the first data line **13a**. Also, the second data line **13b** is disposed along the second light shielding element **12c** and is partially overlapped with the second light shielding element **12c**. The first gate line **11a**, the second gate line **11b**, the first data line **13a** and the second data line **13b** together define a pixel region. It is apparent to one of ordinary skill in the art that the pixel structure **3** can also include a plurality of pixel regions. The difference between the pixel structure **3** in the third embodiment and the pixel structure **1** in the first embodiment (shown in FIG. **4a**) is that the pixel region **3** is the structure of storage capacitor (Cst) on gate, i.e. the pixel structure **3** does not include any common line.

[0038] The first gate line **11a** and the second gate line **11b** are served as scan lines. The first and second gate lines **11a**, **11b** and the conductive line **12** are formed by the same photolithography & etching processes, and hence the first and second gate lines **11a**, **11b** and the conductive line **12** are referred to first metal layer (M1) herein. After the first metal layer is formed, the first and second data lines **13a**, **13b** are formed by the same photolithography & etching processes, and hence the first and second data lines **13a**, **13b** are referred to second metal layer (M2) herein. In this embodiment, the conductive line **12** is made of conductive material, and the first and second light shielding elements **12b**, **12c** are adapted to block light leakage at the edge of the pixel structure **3**.

[0039] The area of the black matrix (not shown) between two adjacent pixels can be reduced by disposing the first and second light shielding elements **12b**, **12c** of the conductive line **12** to block light leakage at the edge of a pixel region so as to increase the transmission rate of a single pixel structure, thereby increasing the aperture ratio of the pixel structure **3**.

[0040] A thin film transistor **14** is disposed adjacent to an intersection of the second gate line **11b** and the first data line **13a**. The thin film transistor **14** includes a gate electrode **141**, a source electrode **142** and a drain electrode **143**, wherein the gate electrode **141** is extended from the second gate line **11b**. A pixel electrode **15** is deposited over the pixel region. The pixel electrode **15** has a first side **15a**, which includes a first portion **151** and a second portion **152**. The first portion **151** is overlapped with the first data line **13a**, and is not overlapped with the first light shielding element **12b**. The second portion

152 is overlapped with the first light shielding element **12b**, and is not overlapped with the first data line **13a**. Also, the pixel electrode **15** has a second side **15b**, which includes a third portion **153** and a fourth portion **154**. The third portion **153** is overlapped with the second data line **13b**, and is not overlapped with the second light shielding element **12c**. The fourth portion **154** is overlapped with the second light shielding element **12c**, and is not overlapped with the second data line **13b**. According to the pixel structure **3** of this embodiment, the parasitic capacitance Cpd existed between the pixel electrode **15** and the data lines **13a**, **13b** can be half decreased, thereby reducing the coupling ratio of the data lines in a single pixel region, and further reducing crosstalk. Furthermore, an overlapping portion of the pixel electrode **15** and the conductive line **12** can be served as storage capacitor.

[0041] In addition, the liquid crystal display panel is operated in a dot inversion mode or a column inversion mode. By utilizing the two adjacent pixel regions having opposite polarity, it can get a formula: " $|Cpd1+Cpd2| < |Cpd1|+|Cpd2|$ ", thereby reducing the coupling ratio of two data lines in a single pixel region, wherein Cpd1 and Cpd2 are parasitic capacitance existed between the pixel electrode and two adjacent data lines respectively, $|Cpd1+Cpd1|$ is the absolute value of the sum of Cpd1 and Cpd2, and $|Cpd1|+|Cpd2|$ is the sum of the absolute value of Cpd1 and the absolute value of Cpd2. Preferably, the overlapping area between the pixel electrode **15** and the first data line **13a** is substantially equal to the overlapping area between the pixel electrode **15** and the second data line **13b**, whereby the value of $|Cpd1|$ is substantially equal to the value of $|Cpd2|$. When the pixel region of the liquid crystal display panel is operated, the pixel region is induced by coupled voltages of opposite polarity from the first and second data lines **13a**, **13b**, Cpd1 and Cpd2 can be offset (i.e. compensated) to each other, thereby further reducing crosstalk. According to the pixel structure **3** of this embodiment, for example, the overlapping area between the first portion **151** of the pixel electrode **15** and the first data line **13a** is substantially equal to the overlapping area between the third portion **153** of the pixel electrode **15** and the second data line **13b**.

[0042] The deposition of other elements in the third embodiment is similar to that in the first embodiment shown in FIG. **4a** and details will not be illustrated herein. Similarly, the third embodiment of the present invention also includes the example having an organic layer (as those shown in FIGS. **6a** and **7a**) and the example without an organic layer (as those shown in FIGS. **6b** and **7b**).

[0043] Referring to FIG. **10**, it shows a top plan view of the pixel structure **4** according to the fourth embodiment of the present invention. The pixel structure **4** shown in FIG. **10** is substantially similar to the pixel structure **3** shown in FIG. **9**, wherein the same elements are designated with the same reference numerals. The difference between the fourth embodiment and the third embodiment is that the first light shielding elements **12b** is separated from the line portion **12d**, and the second light shielding elements **12c** is separated from the line portion **12d**. Thus, the first and second light shielding elements **12b**, **12c** can be made of conductive or insulating material. In addition, the deposition of other elements in the pixel structure **4** shown in FIG. **10** is similar to that in the pixel structure **3** shown in FIG. **9** and details will not be illustrated herein. Similarly, the fourth embodiment of the present invention also includes the example having an organic layer (as

those shown in FIGS. 6a and 7a) and the example without an organic layer (as those shown in FIGS. 6b and 7b).

[0044] Although the invention has been explained in relation to its preferred embodiment, it is not used to limit the invention. It is to be understood that many other possible modifications and variations can be made by those skilled in the art without departing from the spirit and scope of the invention as hereinafter claimed.

What is claimed is:

1. A pixel structure of a liquid crystal display panel comprising:

a substrate;

a first metallic layer disposed above the substrate and comprising first and second gate lines laterally parallel to each other;

a first light shielding element longitudinally disposed above the substrate;

a second metallic layer disposed above the first light shielding element and comprising:

a first data line disposed along the first light shielding element and partially overlapped with the first light shielding element; and

a second data line parallel to the first data line, wherein the first gate line, the second gate line, the first data line and the second data line together define a pixel region; and

a pixel electrode having a first side, which comprises a first portion and a second portion, wherein the first portion is overlapped with the first data line, the first portion is not overlapped with the first light shielding element, the second portion is overlapped with the first light shielding element, and the second portion is not overlapped with the first data line.

2. The pixel structure as claimed in claim 1, wherein:

the pixel structure further comprises a second light shielding element parallel to the first light shielding element; the second data line is disposed along the second light shielding element, and is partially overlapped with the second light shielding element; and

the pixel electrode has a second side, which includes a third portion and a fourth portion, wherein the third portion is overlapped with the second data line, and the third portion is not overlapped with the second light shielding element, the fourth portion is overlapped with the second data line, and the fourth portion is not overlapped with the second light shielding element.

3. The pixel structure as claimed in claim 2, wherein the overlapping area between the pixel electrode and the first data line is substantially equal to the overlapping area between the pixel electrode and the second data line.

4. The pixel structure as claimed in claim 2, wherein the overlapping area between the first portion of the pixel electrode and the first data line is substantially equal to the overlapping area between the third portion of the pixel electrode and the second data line.

5. The pixel structure as claimed in claim 2, wherein the first portion and the third portion are symmetrical at the right and lower position and the left and upper position, and the second portion and the fourth portion are symmetrical at the right and upper position and the left and lower position.

6. The pixel structure as claimed in claim 2, wherein the first portion and the third portion are symmetrical at the right

position and the left position, and the second portion and the fourth portion are symmetrical at the right position and the left position.

7. The pixel structure as claimed in claim 2, wherein:

the first side further comprises a fifth portion, the fifth portion is overlapped with the first data line, and the fifth portion is not overlapped with the first light shielding element; and

the second side further comprises a sixth portion, the sixth portion is overlapped with the second data line, and the sixth portion is not overlapped with the second light shielding element.

8. The pixel structure as claimed in claim 7, wherein the sum of the overlapping area between the first portion of the pixel electrode and the first data line and the overlapping area between the fifth portion of the pixel electrode and the first data line is substantially equal to the sum of the overlapping area between the third portion of the pixel electrode and the second data line and the overlapping area between the sixth portion of the pixel electrode and the second data line.

9. The pixel structure as claimed in claim 2, further comprising a common line electrically connected to the first and second light shielding elements.

10. The pixel structure as claimed in claim 2, further comprising a line portion electrically connected to the first and second light shielding elements and being a part of the first gate line.

11. The pixel structure as claimed in claim 2, wherein the first and second light shielding elements are made of insulating material.

12. The pixel structure as claimed in claim 2, wherein the first and second light shielding elements are made of conductive material.

13. The pixel structure as claimed in claim 2, wherein the first and second light shielding elements and the first metallic layer are made of same material.

14. The pixel structure as claimed in claim 2, wherein the pixel structure comprises a plurality of pixel regions, gate lines and data lines, each pixel region is defined by the two adjacent gate lines and the two adjacent data lines, the pixel regions are adjacent to one another, and the two adjacent pixel regions have opposite polarity.

15. A liquid crystal display panel comprising:

a lower substrate;

a pixel structure comprising:

a first metallic layer disposed above the lower substrate and comprising first and second gate lines laterally parallel to each other;

a first light shielding element longitudinally disposed above the lower substrate;

a second metallic layer disposed above the first light shielding element and comprising:

a first data line disposed along the first light shielding element and partially overlapped with the first light shielding element; and

a second data line parallel to the first data line, wherein the first gate line, the second gate line, the first data line and the second data line together define a pixel region; and

a pixel electrode having a first side, which comprises a first portion and a second portion, wherein the first portion is overlapped with the first data line, the first portion is not overlapped with the first light shielding element, the second portion is overlapped with the

first light shielding element, and the second portion is not overlapped with the first data line;
 an upper substrate opposite to the lower substrate; and
 a liquid crystal layer sandwiched between the lower substrate and the upper substrate.

16. The liquid crystal display panel as claimed in claim **15**, wherein:

the pixel structure further comprises a second light shielding element parallel to the first light shielding element;
 the second data line is disposed along the second light shielding element, and is partially overlapped with the second light shielding element; and

the pixel electrode has a second side, which includes a third portion and a fourth portion, wherein the third portion is overlapped with the second data line, the third portion is not overlapped with the second light shielding element, the fourth portion is overlapped with the second data line, and the fourth portion is not overlapped with the second light shielding element.

17. The liquid crystal display panel as claimed in claim **16**, wherein the overlapping area between the pixel electrode and the first data line is substantially equal to the overlapping area between the pixel electrode and the second data line.

18. A method for driving a liquid crystal display panel comprising the following steps of:

providing a liquid crystal display panel comprising a pixel structure, wherein the pixel structure comprises a plurality of pixel regions, gate lines and data lines, each pixel region is defined by the two adjacent gate lines and the two adjacent data lines; and

getting a formula: " $|Cpd1+Cpd2| < |Cpd1|+|Cpd2|$ " by utilizing the two adjacent pixel regions having opposite polarity, thereby reducing the coupling ratio of two data lines in a single pixel region, wherein Cpd1 and Cpd2 are parasitic capacitance existed between the pixel electrode and two adjacent data lines respectively, $|Cpd1+Cpd2|$ is the absolute value of the sum of Cpd1 and Cpd2, and $|Cpd1|+|Cpd2|$ is the sum of the absolute value of Cpd1 and the absolute value of Cpd2.

19. The method as claimed in claim **18**, wherein the liquid crystal display panel is operated in one of dot and column inversion modes.

20. The method as claimed in claim **18**, wherein the overlapping area between the pixel electrode and the first data line is substantially equal to the overlapping area between the pixel electrode and the second data line, whereby the value of $|Cpd1|$ is substantially equal to the value of $|Cpd2|$.

* * * * *

专利名称(译)	液晶显示面板的像素结构		
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[标]申请(专利权)人(译)	瀚宇彩晶股份有限公司		
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摘要(译)

液晶显示面板的像素结构包括基板，第一金属层，遮光元件，第二金属层和像素电极。第一金属层和遮光元件设置在基板上方。第二金属层设置在遮光元件上方，并包括第一和第二数据线。第一数据线沿着光屏蔽元件设置，并且与光屏蔽元件部分重叠。第二条数据线与第一条数据线平行。像素电极的第一部分与第一数据线重叠，并且不与遮光元件重叠。像素电极的第二部分与遮光元件重叠，并且不与第一数据线重叠。

